Hazem **Mesilhy**

Computational Lithography



About me

Passionate engineer specializing in computational lithography, focusing on EUV mask absorber and reflective multilayer modeling. Skilled in diverse programming languages and disciplines. Committed to pushing technological boundaries and finding innovative solutions. Proven track record of exceeding project goals. Eager to contribute to groundbreaking advancements in lithography and beyond.

Areas of specialization

- Computational Lithography
- Modeling
- Programming
- · Machine learning

Interests

- Programming languages
- Mountain biking

Programming

- Python
- · C++
- · HPC
- Java
- hazem-mesilhy
- hazemiii
- hazemiii.github.io

EXPERIENCE

2019-Present

Research Scientist

ERLANGEN · Germany 9

Specialize in EUV lithography with a focus on mask/shadowing effects, EUV mask enhancement, absorber, and reflective multilayer modeling. Developed a reliable multilayer degradation model. Participated in European project management, student mentoring, customer presentations, and Dr.LiTHO maintenance.

2017-2019

Research Assistant

ERLANGEN · Germany 9

Engaged in first investigations into Hyper-NA EUV (NA of 0.75) feasibility study, while also providing vital support for EUV mask simulations and optimizations across diverse European projects. Participated in debugging, building, and generating installer packages for Dr.LiTHO to ensure smooth customer experiences.

June-Sept. 2015

Intern Programmer

Jaipur · India 💡

Focused on Android development, animation, and widget creation, incorporating machine learning algorithms for efficient unused folder management. Participation in DevOps and the software development cycle, contributing to streamlined server and proxy setup. Customized Chromium and Mozilla browsers for Android using C under Linux environment. Implemented image quality enhancements and filters with OpenCV.

FAU

DEGREES

2023 Ph.D.

2019

FAU · Erlangen 🏦

Master of Science

FAU · Erlangen 🏦

2016 **Bachelor**

FACULTY OF ENGINEERING .

Cairo uni 🟦

SKILLS

- Numerical Optimization
- Optics simulation / modeling

Fraunhofer

Fraunhofe

- Machine Learning
- Linux
- · Problem solving
- Teamwork

Awards

Best Student Paper Award: 2021 SPIE Photomask Technology + EUV Lithography

LANGUAGES

Arabic **English** German

C2 C2 A2

mother tongue

PUBLICATIONS

More than 17 publications: Google Scholar

Talks

- Various SPIE conferences and panels.
- 2022 ASML Technology Conference
- 2023 ASML Technology Conference

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